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# ELE 222E INTRODUCTION TO ELECTRONICS (21604)

Midterm Exam #1 ✍ 19 March 2003 ⌚ 10.00-12.00

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## SOLUTIONS w/CORRECTIONS

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n	p
$\mu_n = 1350 \text{ cm}^2/\text{Vs}$	$\mu_p = 480 \text{ cm}^2/\text{Vs}$
$L_n = 10^{-2} \text{ cm}$	$L_p = 2 \cdot 10^{-3} \text{ cm}$
$N_D = 10^{15} \text{ 1/cm}^3$	

1. A Si diode in the making will have a junction are of  $1 \text{ mm}^2$ . n and p type doped areas will have the properties shown on the left.  
 $n_i = 1.5 \cdot 10^{10} \text{ 1/cm}^3$ ,  $q = 1.602 \cdot 10^{-19} \text{ C}$ ,  $V_T = 25 \text{ mV}$ ,  $\epsilon_r = 12$ ,  $\epsilon_o = 8.85 \cdot 10^{-12} \text{ F/m}$ .
- a. What should  $N_A$  be so that  $I_o \leq 2,5 \text{ pA}$  at room temperature? (15 points)

Using Einstein Eq. , i.e.,  $D_{p/n} = V_T \cdot \mu_{p/n}$ , we find  $D_p = 12 \text{ cm}^2/\text{s}$  and  $D_n = 33.8 \text{ cm}^2/\text{s}$ . If

$$I_o = A \cdot q \cdot n_i^2 \cdot \left[ \frac{D_p}{L_p N_D} + \frac{D_n}{L_n N_A} \right] \leq 2,5 \text{ pA, then for } N_A \geq \frac{\frac{D_n}{L_n}}{I_o - A q n_i^2 \frac{D_p}{L_p N_D}} = 10^{16} \text{ 1/cm}^3.$$

- b. What should the widths of n and p type doped areas ( $d_n$  and  $d_p$ ) be for bulk resistances to be  $R_n = 1 \text{ }\Omega$  and  $R_p = 0,25 \text{ }\Omega$ , respectively? (15 points)

HINT:  $R_{n/p} = \rho_{n/p} \frac{d_{n/p}}{A} = \frac{1}{\sigma_{n/p}} \cdot \frac{d_{n/p}}{A}$  ALSO: You may neglect the width of the depletion layer.

We know  $\sigma_p = q \cdot \left( \frac{n_i^2}{N_A} \mu_n + N_A \mu_p \right)$ ;  $\sigma_n = q \cdot \left( N_D \mu_n + \frac{n_i^2}{N_D} \mu_p \right)$  Thus  $\sigma_p = 0,769 \text{ 1/(\Omega cm)}$  and

$\sigma_n = 0,216 \text{ 1/(\Omega cm)}$ . Inserting these into the hint equation and reorganizing it we obtain  $d_{n/p} = \sigma_{n/p} R_{n/p} A$ . Thus  $d_n = 0,226 \text{ cm} = 2,26 \text{ mm}$  and  $d_p = 19,2 \text{ }\mu\text{m}$ . OBSERVE THE DIFFERENCE IN LENGTHS OF n AND p TYPE DOPED REGIONS!!!!

- c. Calculate the total depletion layer thickness and capacitance without any bias voltage applied to this junction. (10 points)

$$\text{From } V_B = V_T \cdot \ln \left( \frac{N_A \cdot N_D}{n_i^2} \right) = 613 \text{ mV and } w_{dep} = \sqrt{\frac{2 \cdot \epsilon_o \cdot \epsilon_r \cdot V_B}{q} \left( \frac{1}{N_A} + \frac{1}{N_D} \right)} = 94.5 \text{ }\mu\text{m}.$$

SEE THAT NEGLECTING THE WIDTH OF THE DEPLETION LAYER IN p TYPED REGION IN PART (a) HAS NOT BEEN A GOOD IDEA!!!!

Inserting the values into  $C = \epsilon_o \cdot \epsilon_r \frac{A}{w}$  we obtain  $C = 112 \text{ pF}$ .

Device	$I_C$ (mA)	$I_B$ (mA)	$I_E$ (mA)	$\alpha$	$\beta$
1	2,0	0	2,0	1	$\infty$
2	1,0	0,01	<del>1,4</del> 1,01	0,99	100
3	0,5	0,0025	<del>1,2</del> 0,51	0,98	200
4	0,8	<del>0,08</del> 0	0,8	1	$\infty$

2. Measurements taken on a variety of transistors are incomplete and possibly in error. The submitted data are given on the left. Provide missing data and correct for inconsistent and/or wrong data. (20 points)

First remember a few definitions:

$$I_E = (\beta + 1) I_B$$

$$I_C = \beta I_B$$

$$\alpha = I_C / I_E$$

Now look at the four devices:

1. Assume given data are correct. If  $\beta = \infty$  then  $I_C = I_E$  and thus  $\alpha = 1$  and  $I_B = 0$ .
2. Assuming  $I_C = 1$  mA and  $\beta = 100$  are correct.
3. Assuming  $I_C = 1$  mA,  $\alpha = 0,98$  and  $\beta = 200$  are correct.
4. Assuming  $I_C = 0,8$  mA, and  $\alpha = 1$  are correct.

3. For the circuits shown on the right, find the collector currents of both transistors ( $|V_{BE}| = 0.6$  V), and the labelled node voltages ( $V_1$ ,  $V_2$ ,  $V_3$ ,  $V_4$  and  $V_5$ ) for

- a.  $h_{FE} = \beta = \infty$  (20 points)

Automatically,  $V_1 = 0$  V and thus  $V_2 = 0.6$  V.

$$I_{E1} = (V_{CC} - V_2) / 9k1 = 1,03 \text{ mA.}$$

THUS  $I_{C1} = 1,03$  mA.

$$V_3 = -V_{EE} + I_{C1} * 9k1 = -0,6 \text{ V.}$$

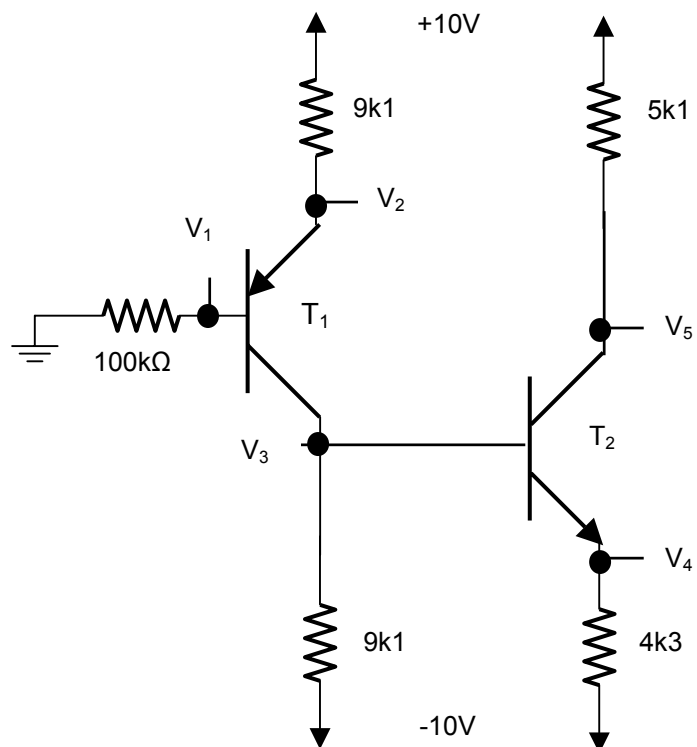
Therefore  $V_4 = -1,2$  V.

$$I_{E2} = (V_4 - V_{EE}) / 4k3 = 2,05 \text{ mA.}$$

THUS  $I_{C2} = 2,05$  mA.

$$V_5 = V_{CC} - I_{C2} * 5k1 = -0,45 \text{ V.}$$

This last value makes sure that  $T_2$  is still in the active region because CB junction is reverse biased.



- b.  $h_{FE} = \beta = 100$  (20 points)

Direction 1: From ground over 100k to  $V_{CC}$ .

$$I_{C1} = h_{FE} \cdot \frac{V_{CC} - (-V_{BE1})}{100k + h_{FE} 9k1} = 0,93 \text{ mA. } V_1 = I_{B1} * 100k = 0,93 \text{ V and } V_2 = 1,53 \text{ V.}$$

Loop 2: From  $-V_{EE}$  over  $C_1$  to  $B_2$  to  $E_2$  to  $-V_{EE}$ .

$$I_{C2} = h_{FE} \cdot \frac{9k1 * I_{C1} - V_{BE2}}{9k1 + (1 + h_{FE}) 4k3} = 1,77 \text{ mA. } V_3 = -V_{EE} + 9k1 (I_{C1} - I_{B2}) = -1,70 \text{ V.}$$

Therefore  $V_4 = -2,30$  V.  $V_5 = V_{CC} - 5k1 * I_{C2} = 0,95$  V.